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ELECTRICAL PROPERTIES OF SILVER PHOTODOPED AMORPHOUS RED PHOSPHORUS

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ABSTRACT Effects of photodoping and thermal doping of silver into sputtered amorphous red phosphorus films (a-P_{red}) on the electrical properties are studied. The d.c. electrical conductivity of the photodoped a-P_{red} at room temperature is about 1×10^{-5} Scm⁻¹ which is a very high value comparing with that of the undoped a-P_{red} (1×10^{-14} Scm⁻¹). The activation energy for the conduction of the photodoped a-P_{red} is lower than that of the a-P_{red}. In contrast, the activation energy of the thermally doped a-P_{red} is essentially the same as that of the undoped a-P_{red}. SEM-EDX analyses show that colloidal silver was deposited in the thermally doped a-P_{red} but not in the photodoped a-P_{red}. It seems that the photodoping involves the ionization process of silver by illumination, i.e., Ag⁰ \longrightarrow Ag⁺ + e⁻.

1. INTRODUCTION

Light induced reaction between silver and amorphous chalcogenides called "photodoping" has been reported by many investigators 1. Some investigators have shown the possibility of technical application of this phenomenon but the mechanism is not known yet 2).

In our previous papers, the authors reported that amorphous red phosphorus film $(a-P_{red})$ was found to show photodarkening, photodoping and photobleaching effects; $a-P_{red}$ is not chalcogen element but pnictide element³⁾. It is known that these effects are commonly observed in amorphous chalcogenide alloys.

The objects of this work are to investigate the effects of silver doping into $a-P_{\mbox{red}}$ on the electrical conduction and to elucidate the mechanism of the doping.

2.RESULTS AND DISCUSSION

2.1 Photodoping in amorphous red phosphorus

Amorphous red phosphorus films were deposited on a 0.5 mm Pyrex glass substrate by r.f. sputtering technique, thick and subsequently silver was evaporated onto the as-sputtered The specimen of the a-P_{red} a-Pred films. films with the silver thin layer was employed for examining the photodoping Illumination was carried out by 500W Xe-arc-lamp cut-off filter with an IR in order to avoid the thermal influence.

The diffusion of silver into the a- P_{red} films was monitored by the recovery of optical transmission as shown in figure 1.

The gradual increase in the transmission was observed during illumination. The transmission increase observed here was caused by the decrease in thickness of the silver layer, from which silver diffuses into the a-P_{red} film on illumination.

This result was directly confirmed by measuring the depth profile of silver in the photodoped film, using secondary ion mass spectroscopy (SIMS). Ιt found in this experiment that silver photodoping takes place in the a-Pred, in which no concentration of silver is obgradient served.(fig.2)

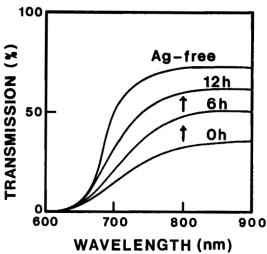


FIGURE 1 Changes in optical transmission of Ag-evaporated a-P $_{\mbox{\scriptsize red}}$ film.

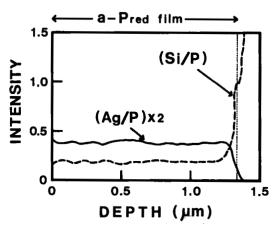


FIGURE 2 Depth profile of the silver photodoped a-P_{red}.(SIMS)

2.2 Effects of silver doping on the electrical conductivity

Figure 3 shows the relation between the electrical conductivity (o) and the inverse temperature (1/T). The conductivity of the assputtered a-P_{red} is 1×10^{-14} Scm⁻¹ room temperature. The activation energy is about 0.85 eV, which is the same as that of thermally silver-doped specimen.

On the other hand, the conductivity and the activation energy for the photodoped specimen are markedly changed, respectively, as seen in figure 3. The conductivity of silver photodoped specimen at room temperature $1x10^{-5}$ Scm⁻¹ which is much higher than that of the a-P_{red}, and the activation energy is about 0.35 eV.

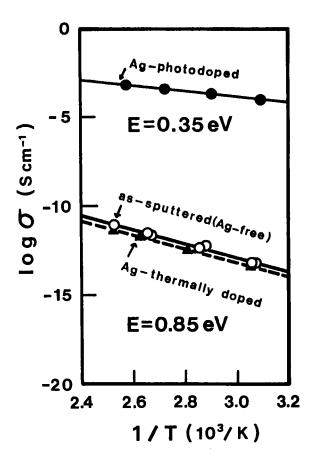


FIGURE 3 $\log \sigma$ vs 1/T plots

2.3 Observation of silver doped a-Pred by SEM-EDX

Figure 4 shows SEM micrograph and results of the silver concentration analysis by EDX along the indicated cross line in the photo for thermally silver-doped a-P_{red}. The patterns like snow-crystal observed by SEM were found by EDX to consist of colloidal silver. It is deduced that atomic

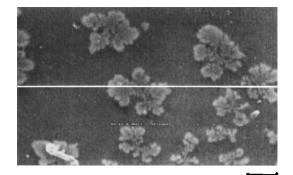
(Ag⁽⁾) diffuses silver into the a-P_{red} subsequently associates with each other to form colloid, so as to decrease the surface energy. This supports the results that the activation energy for the thermally silver-doped specimen is essentially same as that for undoped specimen.

However, no colloid was observed in the photodoped $a-P_{red}$.

These results suggest that the thermally doped species is Ag^0 and the photodoped species is Ag^+ . (fig.5)

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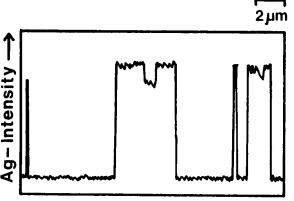


FIGURE 4 SEM-EDX analysis

$$Ag^{\circ} \xrightarrow{h\nu} Ag^{+} e^{-}$$

$$ion$$

$$Ag^{\circ} \xrightarrow{\Delta H} (Ag^{\circ})_{n}$$

$$colloid$$

FIGURE 5 Mechanisms of silver doping

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